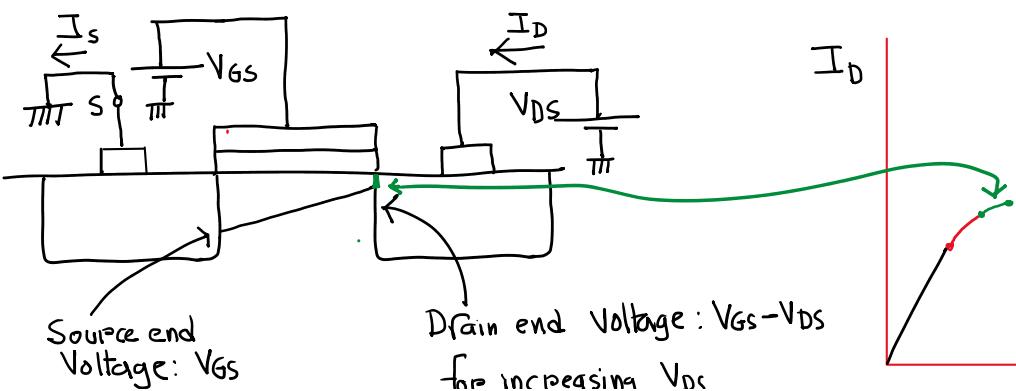
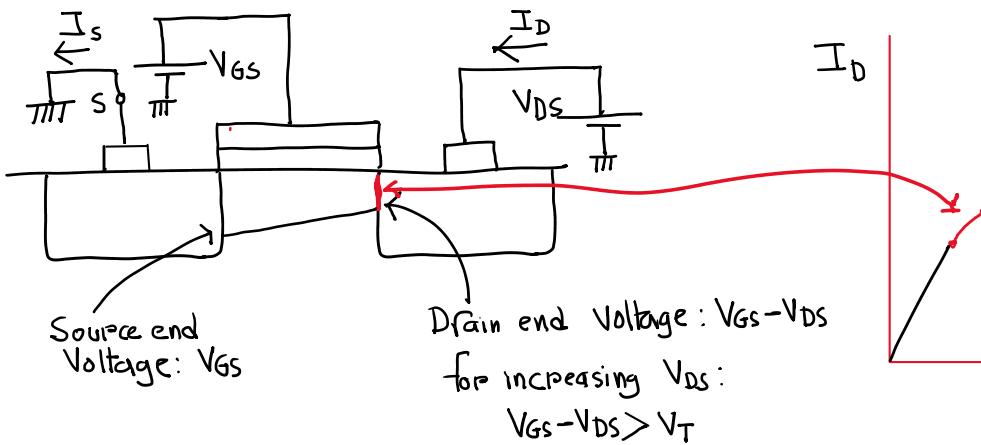
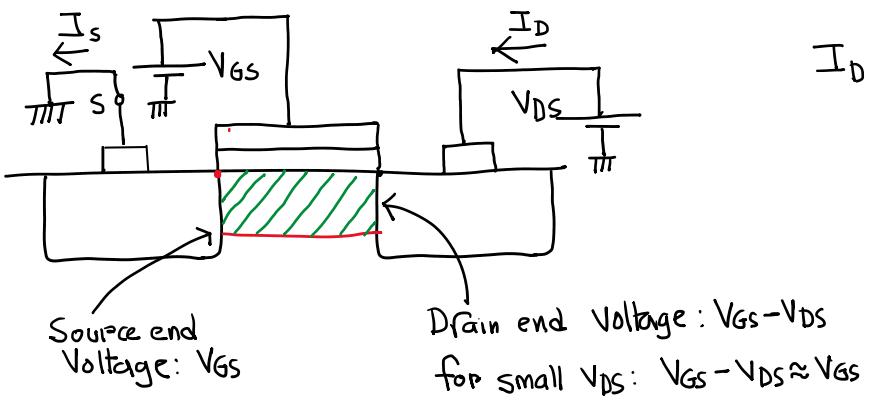
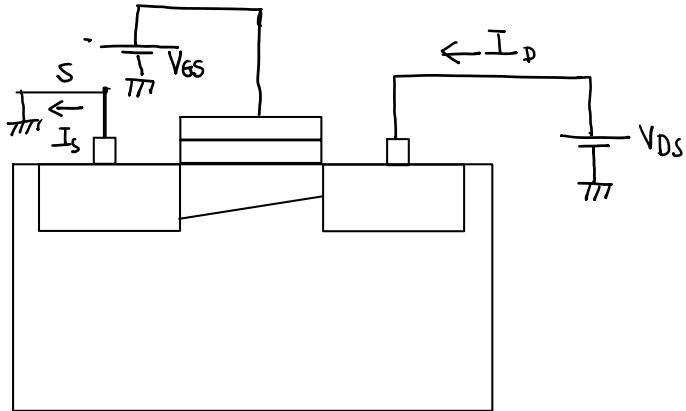


MOSFET Region

Friday, November 15, 2024 9:19 AM

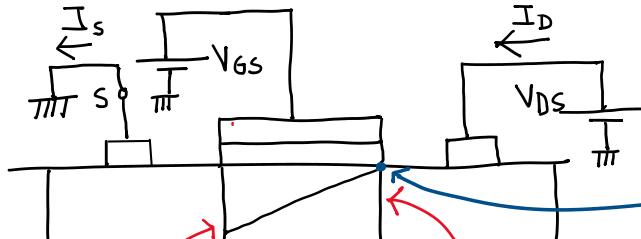


Source end
Voltage: V_{GS}

Drain end Voltage: $V_{GS} - V_{DS}$
for increasing V_{DS}
 $V_{GS} - V_{DS} > V_T$

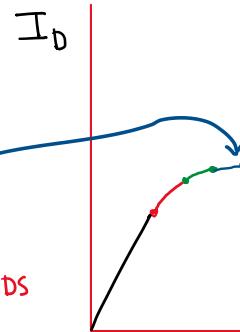


V_{DS}

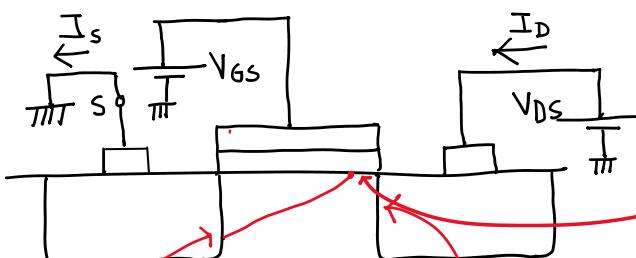


Source end
Voltage: V_{GS}

Drain end Voltage: $V_{GS} - V_{DS}$
for increasing V_{DS}
 $V_{GS} - V_{DS} = V_T$

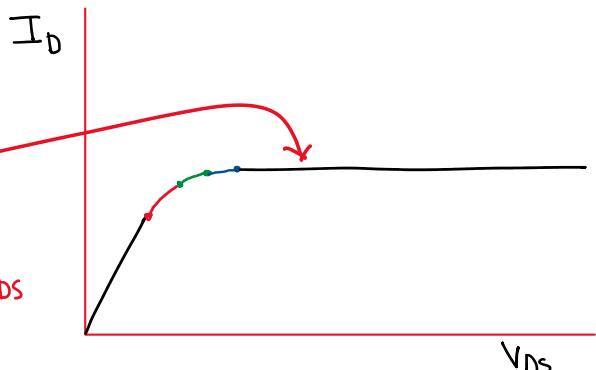


V_{DS}

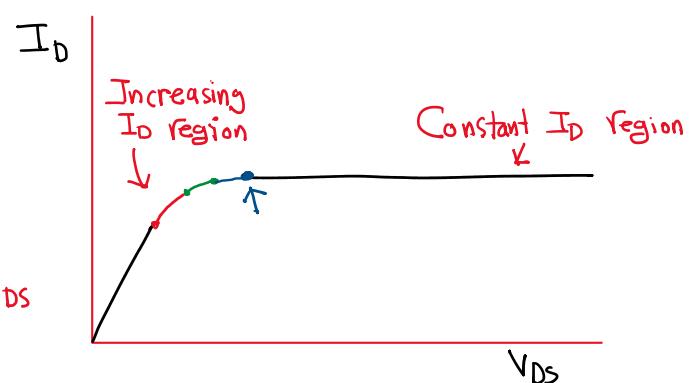


Source end
Voltage: V_{GS}

Drain end Voltage: $V_{GS} - V_{DS}$
for increasing V_{DS}
 $V_{GS} - V_{DS} < V_T$



V_{DS}



Increasing I_D region $\rightarrow V_{GS} - V_{DS} > V_T \rightarrow$ channel exists at drain end

Constant I_D region $\rightarrow V_{GS} - V_{DS} < V_T \rightarrow$ No channel exists at drain end

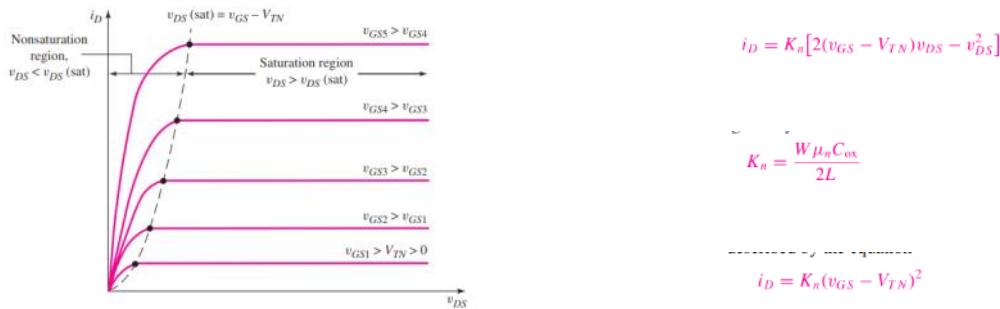


Figure 3.10 Family of i_D versus v_{DS} curves for an n-channel enhancement-mode MOSFET. Note that the $v_{DS}(\text{sat})$ voltage is a single point on each of the curves. This point denotes the transition between the nonsaturation region and the saturation region